

Zn

ZINC SPUTTERING TARGET

Zinc is a chemical element with symbol Zn and atomic number 30. zinc has good electromagnetic field resistance properties, thin zinc films obtained by sputtering targets are very effective shielding material. Zinc is a metal that is used in many applications in many different ways. By the advance in technology zinc sputtering targets are started to be used to make thin films and have outstanding properties.

Quick Facts

Product	:	Zinc Sputtering Target
Stock No	:	NS6130-10-1190
CAS	:	7440-66-6
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1190	99.99%	50.8 mm \pm 1mm	3 mm \pm 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
Zn	65.38g/mol	419.53°C



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 High Purity
 SPUTTERING
 TARGET